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	GROT, S., A., et al. "Oxygen Based Electron Cyclotron Resonance Etching of Semiconducting Homoepitaxial Diamond Films," APPLIED PHYSICS LETTERS,  AMERICAN INSTITUTE OF PHYSICS. NEW YORK, US, vol. 61, no. 19, 9 November 1992, pp. 2326-2328, XP000324738, ISSN: 0003-6951.														
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